

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.	:	10/791,763
Applicant	:	Wolfgang Dettman et al.
Confirmation No.	:	4420
Filed	:	March 4, 2004
TC/A.U.	:	1756
Examiner	:	Ruggles, John S.
Customer No.	:	54500
Docket No.	:	3000.0036C
Title	:	Set of At Least Two Masks for the Projection of Structure Patterns and Method for Producing the Masks

**AMENDMENT**

Mail Stop: Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed on March 22, 2007, please amend the above-identified application as follows:

No extension of time or other fees are believed to be due, except as detailed in the attached documents. However, any extension of time necessary to prevent abandonment is hereby requested, and any fee necessary for consideration of this response is hereby authorized to be charged to Deposit Account Number 05-0460.

**Amendments to the Specification:** begin on page 2 of this paper.

**Amendments to the Claims:** reflected in the listing of claims that begins on page 4 of this paper.

**Amendments to the Drawings:** begin on page 6 of this paper and include attached replacement sheets.

**Remarks:** begin on page 7 of this paper.